FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE
(Rev. 2-2001) PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.
1199-4SERIAL NO.
10/074,272INFORMATION DISCLOSURE
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EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
<i>LMZ</i>	4,562,020	12/31/1985	Hijiya et al.	—	—	
<i>LMZ</i>	4,623,394	11/18/1986	Nakamura et al.	—	—	
<i>LMZ</i>	4,925,670	05/15/1990	Schmidt	—	—	
<i>LMZ</i>	4,927,636	05/22/1990	Hijiya et al.	—	—	
<i>LMZ</i>	4,981,693	01/01/1991	Higashi et al.	—	—	
<i>LMZ</i>	5,028,632	07/02/1991	Fulsz	—	—	
<i>LMZ</i>	5,393,528	02/28/1995	Staab	—	—	
<i>LMZ</i>	5,411,945	05/02/1995	Ozaki et al.	—	—	
<i>LMZ</i>	5,518,902	05/21/1996	Ozaki et al.	—	—	
<i>LMZ</i>	5,567,431	10/22/1996	Vert et al.	—	—	
<i>LMZ</i>	6,153,210	11/28/2000	Roberts et al.	—	—	
<i>LMZ</i>	2001/0006 677	07/05/2001	McGinty et al.	—	—	

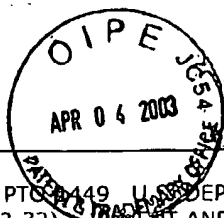
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FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION	
							YES	NO
MAC		WO 00/18365	04/06/2000	PCT	—	—		
MAC		WO 00/42992	07/27/2000	PCT	—	—		
MAC		WO 01/70194	09/27/2001	PCT	—	—		
MAC		WO 01/91721	12/06/2001	PCT	—	—		
MAC		O 241 178 A1	10/14/1987	EPO	—	—		
MAC		O 514 691	11/25/1992	EPO	—	—		
MAC		EP 1 110 546	06/27/2001	EPO	—	—		

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

MAC			Lazaridou et al.; Thermophysical properties of chitosan, chitosan-starch and chitosan-pullulan films near the glass transition; Elsevier Science Ltd.; 2002; pp 179-190.
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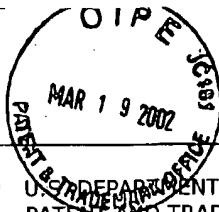
EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
MM	3,753,732	08/21/73	Boroshok	✓	✓	
MM	4,029,758	06/14/77	Mlodozeniec et al.	✓	✓	
MM	4,031,200	06/21/77	Reif	✓	✓	
MM	4,128,445	12/05/78	Sturzenegger et al.	✓	✓	
MM	4,136,145	01/23/79	Fuchs et al.	✓	✓	
MM	4,713,239	12/15/87	Babaian et al.	✓	✓	
MM	4,777,046	10/11/88	Iwakura et al.	✓	✓	
MM	4,849,246	07/18/89	Schmidt	✓	✓	
MM	4,876,092	10/24/89	Mizobuchi et al.	✓	✓	
MM	4,900,552	02/13/90	Sanvordeker et al.	✓	✓	
MM	5,089,307	02/18/92	Ninomiya et al.	✓	✓	
MM	5,234,957	08/10/93	Mantelle	✓	✓	
MM	5,346,701	09/13/94	Heiber et al.	✓	✓	
MM	5,620,757	04/15/97	Ninomiya et al.	✓	✓	
MM	5,629,003	05/13/97	Horstmann et al.	✓	✓	
MM	5,700,478	12/23/97	Biegajski et al.	✓	✓	
MM	5,948,430	09/07/99	Zerbe et al.	✓	✓	

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EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
MAC	6,177,096	01/23/01	Zerbe et al.	—	—	
MAC	6,231,957	05/15/01	Zerbe et al.	—	—	
MAC	6,284,264	09/04/01	Zerbe et al.	—	—	
MAC	0046511 A1*	11/29/01**	Zerbe et al.	—	—	
MAC	RE 33,093	10/17/89	Schiraldi et al.	—	—	

* Publication

** Publication date

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION	
						YES	NO
MAC	EP 200508	10/02/91	EPO	—	—		
MAC	EP 273069	10/14/92	EPO	—	—		
MAC	EP 381194	08/31/94	EPO	—	—		

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

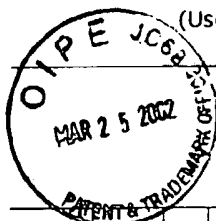
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U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
<i>ML</i>	US 2001/0022964 A1*	09/20/01**	Leung et al.			

* Publication

** Publication date

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						YES	NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

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